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Skin Care and Cosmetics: Chemical Analysis and Dermatology

Guest Editor:

Prof. Dr. Yoshihiro Tokudome

Laboratory of Cosmetic Sciences, Regional Innovation Center, Graduate School of Advanced Health Sciences, Saga University, 1, Honjyo, Saga 840-8502, Japan

Deadline for manuscript submissions:

closed (20 August 2023)

Message from the Guest Editor

Dear Colleagues,

Cosmetic products play a significant role in today's society, but many of them are composed of chemical substances. As such, it is of great importance to carry out research that helps us to understand the efficacy and safety of these cosmetics. This field of research is known as cosmetology, which is an applied science that involves organic chemistry, analytical chemistry, formulation science, biology, dermatology, and material science, among others. In this Special Issue, we invite a wide range of papers related to cosmetics.

Keywords

- cosmetics
- skin care
- cosmetology
- cosmetic active Ingredients
- skin
- dermatology
- skin disease
- pharmaceuticals
- organic chemistry
- analytical chemistry
- formulation science
- biology
- material science











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Editor-in-Chief

Prof. Dr. Giulio Nicola CerulloDipartimento di Fisica, Politecnico di Milano, Piazza L. da Vinci 32, 20133 Milano, Italy

Message from the Editor-in-Chief

As the world of science becomes ever more specialized, researchers may lose themselves in the deep forest of the ever increasing number of subfields being created. This open access journal Applied Sciences has been started to link these subfields, so researchers can cut through the forest and see the surrounding, or quite distant fields and subfields to help develop his/her own research even further with the aid of this multi-dimensional network.

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